

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: SEOK-YOON YANG, ET AL.)
) Group Art Unit:
Serial No.: 10/675,455) 1752
)
Filed: September 30, 2003) Examiner:
) Walke, Amanda C.
For: PHOTSENSITIVE RESIN COMPOSITION)
)
) CONTROLLING SOLUBILITY AND PATTERN)
) FORMATION METHOD OF DOUBLE-LAYER)
) STRUCTURE USING THE SAME)

RESPONSE

VIA EFS

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir,

This Response is being filed in response to the Office Action dated September 24, 2007. A petition for a 2 month extension of time, from December 24, 2007 to February 24, 2008, accompanies this Response.